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(71) Applicant (for all designated States except US): **LITE-LASER L.L.C.** [US/US]; 39533 Woodward Avenue, Suite 340, Bloomfield Hills, MI 48304 (US).

(72) Inventor; and

(75) Inventor/Applicant (for US only): **MONTY, Nathan Paul** [US/US]; 120 Osgood Road, Charlton, MA 01507 (US).

(74) Agent: **OLDS, Mark, E.**; KCO Law PLLC, P.O. Box 220472, Chantilly, VA 20153-0472 (US).

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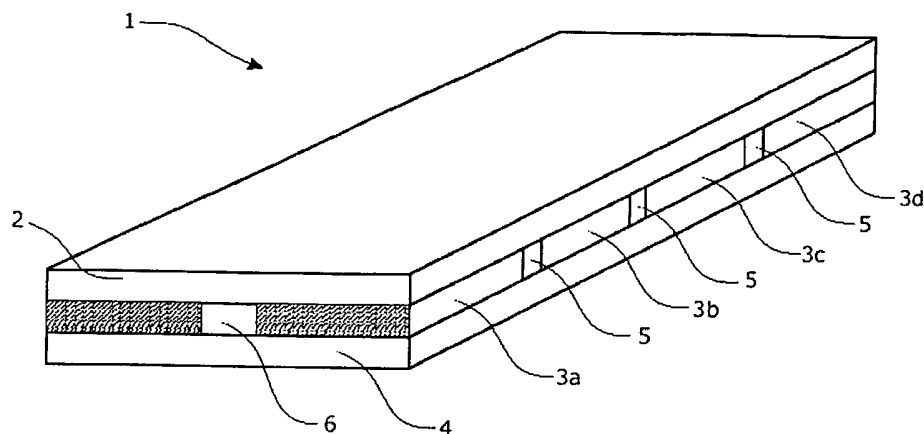
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(54) Title: WAVEGUIDE LASER



(57) Abstract: A laser waveguide, where the laser waveguide can be formed by electrodes and at least one sidewall in a manner allowing a more compact structure than previously provided. Protrusions in the electrodes allow easier laser starts, and sectional sidewall(s) allow easier fabrication of sidewall(s), decreasing manufacturing costs.



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## WAVEGUIDE LASER

### CROSS-REFERENCE TO RELATED APPLICATIONS

[0001] This application claims the benefit of U.S. provisional patent application No. 60/467,542 filed on 2 May 2003.

### FIELD OF THE INVENTION

[0002] The invention relates in general to waveguide lasers and particularly but not exclusively to RF excited waveguide lasers.

### BACKGROUND OF THE INVENTION

[0003] A waveguide laser typically consists of two mirrors, concave or flat, defining an optical resonator cavity coupled together with a waveguide defining an optical path between the mirrors.

[0004] The waveguide is typically a channel ground into a ceramic block (e.g. aluminum oxide,  $\text{Al}_2\text{O}_3$ ) with a lower electrode of aluminum or copper added to complete a cross-section of the waveguide. Alternatively, the waveguide can be ultrasonically drilled down through a piece of ceramic such as aluminum oxide ( $\text{Al}_2\text{O}_3$ ) to create a continuous closed bore length with upper and lower electrodes parallel to the bore length. Typically, the positive arm of the oscillating electromagnetic field (e.g. Radio Frequency –RF) supply will be coupled into the upper electrode of the waveguide, and the ground plane of the RF supply will be coupled to the lower electrode. Resonance is added between and along the length of the upper electrode to distribute the RF voltage evenly along the length of the electrodes. Finally, the

mirrors and waveguide structure are aligned and housed in a vacuum vessel (laser housing) that holds the gas to be excited.

**[0005]** Waveguide lasers suffer from the disadvantage that, for the lengths needed, the waveguides are difficult to fabricate with sufficient accuracy at a reasonable cost to obtain acceptable laser performance. It is very difficult to cost-effectively fabricate a typical waveguide structure that is roughly 30 to 40 cm long with a 1.5 to 3.0mm bore. Bore cross-section inaccuracy leads to unacceptable laser transverse mode characteristics and reduced power output. Due to the size, current ceramic slabs used to manufacture waveguides are constructed by casting or extruded. Casting or extruding tolerances are high, requiring expensive machining (grinding) after the piece is formed to acquire the desired accuracy.

**[0006]** Additionally, a waveguide laser balances its loss in inherent internal RF circuit, and heat removal efficiency. Ideally, to minimize the RF losses the capacitance between the top and bottom electrodes (RF+ and RF- or ground) needs to be high, which translates into using as little ceramic as possible between the top and bottom electrodes. With  $\text{Al}_2\text{O}_3$ , thermal efficiency requirements dictate the use of a large ceramic area, which creates either a higher loss RF circuit, and/or high manufacturing costs. Ideally materials with good thermal properties such as BeO and AlN are desirable ceramics to use, but are prohibitively expensive with related art waveguide designs.

**[0007]** Additionally, the resonator cavities of waveguide lasers suffer energy losses from misalignment of the containment mirrors and low

reflectivity properties of the containment. For example, the use of planar mirrors at either end of the resonator cavity, unless perfectly aligned, enable only a limited number of reflections.

**[0008]** Since the bore cross-sections, in the related art, are the result of grinding or ultrasonic drilling, most bores are either rectangular or circular. This results in bores that are optimized for the manufacturing process rather than the optical properties of the device. For example, the use of curved containment mirrors results in variable beam radius throughout the resonator cavity, thus the waveguide channels of related art fail to allow the optimization of the waveguide with respect to variable beam radius in the resonator channel.

**[0009]** In related art, the electrode positioning, and subsequent resonance electric field generation, is partly a function of the electrode spacing, and is often determined by the size of the waveguide structure (i.e. the distance between electrodes). Various spacing between electrodes results in varying power levels and the related art fails to fully optimize the electrode spacing and optics, and instead conventional methods focus on ease of manufacture.

**[0010]** Additional problems exist in conventional gaseous lasers, for example, laser startup. Traditional CO<sub>2</sub> lasers are pressurized at 70-80 torr and have difficulty starting without some manipulation of the RF system.

**[0011]** A related art system is described in Laakmann (U.S. Patent No. 4,169,251). Laakmann is directed to a conventional waveguide laser that suffers from many of the same problems as other conventional

systems (e.g., expensive long ceramic pieces that must be formed via casting, conventional startup characteristics...).

### **SUMMARY OF THE INVENTION**

**[0012]** Exemplary embodiments of the present invention provide methods of gaseous laser construction.

**[0013]** Exemplary embodiments of the present invention provide methods and devices for the use of ceramic portions in the formation of laser waveguides.

**[0014]** Exemplary embodiments of the present invention provide methods and devices for the use of protrusions (e.g., electrode corner radii...) in the formation of laser waveguide structures.

**[0015]** Exemplary embodiments of the present invention provide methods and devices for the combination of protrusions with the use of ceramic portions in the formation of laser waveguides.

**[0016]** Exemplary embodiments of the present invention provide for increased laser power and/or efficiency by optimizing electrode spacing.

**[0017]** An exemplary embodiment of the present invention provides a waveguide laser having a waveguide located in a laser resonator cavity defined by a first and second reflecting means at opposite ends of the waveguide enclosed in a sealed vessel. The waveguide structure is made up of multiple pieces that when joined together form the waveguide walls. The waveguide walls can be made up of individual pieces that allow the walls to be more accurately aligned. The individual pieces can be abutted one to

another, or can be separated by a gap with little degradation in the laser power or mode.

**[0018]** Further areas of applicability of embodiments of the present invention will become apparent from the detailed description provided hereinafter. It should be understood that the detailed description and specific examples, while indicating exemplary embodiments of the invention, are intended for purposes of illustration only and are not intended to limited the scope of the invention.

### **BRIEF DESCRIPTION OF THE DRAWINGS**

**[0019]** Embodiments of the present invention will become apparent from the following detailed description, taken in conjunction with the drawings in which:

**[0020]** Figure 1 shows a perspective view of a slab waveguide laser according to an exemplary embodiment of the present invention;

**[0021]** Figure 2 shows a cross-sectional view of a waveguide laser according to an exemplary embodiment of the present invention;

**[0022]** Figure 3 shows a longitudinal view of section IV-IV of Figure 4 of a laser, according to an exemplary embodiment of the present invention;

**[0023]** Figure 4 shows an end view from the output coupler end of the laser, according to an exemplary embodiment of the present invention;

**[0024]** Figure 5 shows an enlarged view of a waveguide section according to an exemplary embodiment of the present invention;

**[0025]** Figures 6A-6E show various laser waveguide cross sections in accordance with exemplary embodiments of the present invention;

**[0026]** Figure 7 shows a cross-section of a variable lengthwise waveguide in accordance with exemplary embodiments of the present invention;

**[0027]** Figure 8 illustrates an exploded view of a waveguide with single piece ceramic sidewall forming the walls of a waveguide structure in accordance with an exemplary embodiments of the present invention;

**[0028]** Figures 9A-9C show various waveguide electrode protrusions in accordance with exemplary embodiments of the present invention; and

**[0029]** Figure 10 illustrates a power source connection in accordance with exemplary embodiments of the present invention.

#### **DETAILED DESCRIPTION OF EXEMPLARY EMBODIMENTS OF THE PRESENT INVENTION**

**[0030]** The following description of exemplary embodiment(s) is merely illustrative in nature and is in no way intended to limit the invention, its application, or uses.

**[0031]** Figure 1 shows a slab waveguide laser 1 according to an exemplary embodiment of the present invention, comprising a top or upper electrode 2 and a bottom or lower electrode 4. The upper and lower electrodes, 2 and 4 respectively, can have variable shape (e.g., planar,



variable thickness, curved...). Sidewalls 3a, 3b, 3c, and 3d are sandwiched between the upper electrode 2 and the lower electrode 4 and can be separated by small gaps 5. The width and thickness of the sidewalls are shown shaded. The length of the sidewalls is not shaded.

**[0032]** The sidewalls 3a, 3b, 3c, and 3d and the upper and lower electrodes 2 and 4 respectively can form a waveguide 6. There can be gaps 5 between the sidewalls 3a, 3b, 3c, and 3d or no gap. In exemplary embodiments of the present invention there can be any number of gaps. In additional exemplary embodiments of the present invention, the sidewalls can seal the waveguide 6 at a predetermined pressure. The waveguide 6 can be sealed at various pressures depending upon the lasing medium or desired operating conditions. For example the waveguide can have electrodes 2 and 4, side walls 3a, 3b, 3c, and 3d with no gaps. In this exemplary embodiment the side walls 3a, 3b, 3c, and 3d extend and surround the electrodes 2 and 4 to form the housing of the laser itself. Likewise the electrodes 2 and 4 can form the housing of the laser (e.g., Figure 6C).

**[0033]** The sidewalls 3a, 3b, 3c and 3d (etc) act to guide the beam to an extent that there is little or no appreciable beam degradation or power loss even if there are gaps between the sections of the sidewalls or sections of the sidewalls and electrodes 2 and 4. Gaps 5 can be of variable size (e.g. 1-3mm or more,...) without affecting the beam. Figure 2 shows an end-on view through a transverse section of the waveguide laser 1 of figure 1. The upper electrode 2 and the lower electrode 4 are shown shaped so as to form the waveguide 6, with rounded corners (protrusions). The shape of the electrodes 2 and 4 are easily changed such that easier striking and better

mode control of the beam is provided. In waveguided lasers and other types of lasers, it is desired for circular symmetry to exist in the beam, which will produce the typical Gaussian shape to the beam intensity. The electrodes may be rounded further than is shown such that there is complete circular symmetry in the waveguide, i.e. the waveguide is completely circular in cross-section (e.g. as shown in waveguide 6 of Figure 6A). In accordance with exemplary embodiments of the present invention the variable shaping of the cross section of the electrodes can be shaped by conventional methods (e.g., by CNC Milling,...).

**[0034]** Figure 3 shows a longitudinal view of section IV-IV of Figure 4 in accordance with an exemplary embodiment of the present invention. The laser 1 can be disposed within a housing 11 and comprises a cavity contained between the two ends 1a and 1b. End 1a comprises a reflective surface and end 1b comprises a partially reflective surface which forms the output coupler. The RF feed-through 12 can be encircled in an insulating ceramic casing 13. The ceramic casing 13 can be comprised of various materials (e.g., BeO, AlN, Al<sub>2</sub>O<sub>3</sub>, other suitable insulating and/or dielectric material(s)). Although discussion herein has referred to various components, the arrangement of such components and the presence of such components should not be interpreted as being limitative on the scope of the present invention. For example, in accordance with exemplary embodiments of the present invention, a separate housing is not needed in a sealed waveguide structure containing reflective elements, where the sidewalls or electrodes additionally form the housing.

**[0035]** The laser 1 can be contained in a housing 11, with an electrode top or upper plate 2 and bottom or lower electrode plate 4. The top or upper electrode 2 is shown here as continuous but can also comprise one or more sections to assist in alleviating warping due to temperature differentials between the topside and bottomside of the electrodes. The waveguide 6 can be between a total reflector 14 and a partially reflecting surface 15. The total reflector 14 and partially reflecting surface 15 can be placed at the waveguide's 6 ends. The partially reflecting surface 15 can form the output coupler for the beam. The beam can make one or more passes through the waveguide before exiting at the output coupler. Exemplary embodiments of the present invention should not be interpreted to be limited with regard to the number of waveguides placed between the total reflector 14 and the partially reflective surface 15. Exemplary embodiments of the present invention can have multiple waveguides, where the waveguides can be connected or separate.

**[0036]** The exemplary embodiment of Figure 3 illustrates a case where the ceramic sidewalls, 3a, 3b, 3c, 3d, 3e are abutted to each other, leaving no gaps. In this embodiment of the invention, four ceramic cylinders 16a, 16b, 16c and 16d are used to provide a clamping force between the laser housing and the electrode assembly to hold the laser together. The cylinders 16a, 16b, 16c, 16d can be made of various materials (e.g., BeO, AlN or Al<sub>2</sub>O<sub>3</sub>, other suitable ceramic,...). They are shown here each provided with an inductor 17a, 17b, 17c, 17d, which ensures that the voltage difference along the length of the laser is minimized. In exemplary embodiments, at least one power source can be connected via connector 12.

**[0037]** Screw adjustors 18a and 18b can be used to adjust the optics. Other adjustors can be used to adjust the optics in other planes. Embodiments of the present invention are not limited by the type of optical adjuster and other methods commonly known by one of ordinary skill can be used. The present invention is also not limited to having an optical adjustor.

**[0038]** Figure 4 shows an end on view of a laser in accordance with an exemplary embodiment of the present invention. Two optic adjustment means 18 can be placed orthogonal to each other to facilitate the adjustment of the optics in two planes, both perpendicular to the optical axis of the beam, the optical axis lying parallel to the bore 6. Other adjustment means, not shown, can be used for adjustment of the optics in the direction parallel to the beam.

**[0039]** Figure 5 shows an enlarged view of the electrodes and waveguide of Figure 2 in accordance with an exemplary embodiment of the present invention, showing more clearly the electrodes 2 and 4. The electrodes 2 and 4 are profiled to provide a shaped waveguide 6. The electrodes 2 and 4 can be formed with any desired shape to optimize power and beam quality. The profile portion of the electrodes is herein also referred to as a protrusion(s).

**[0040]** Figures 6A-6E show various cross sections of waveguides 6 in accordance with exemplary embodiments of the present invention. In Figures 6A through 6D, the waveguides 6 are surrounded by electrodes 2 and 4 and side wall pieces 9A and 9B. The electrodes 2 and 4 and the sidewall(s) can have gaps and not lie flush upon each other. Figure 6C shows the use of an electrode 2 to form a majority of the housing of a laser waveguide in

accordance with an exemplary embodiment of the present invention. Electrode 2 is separated from electrode 4 by an insulative spacer 10, which can be a protruded part of the ceramic side walls 9A and 9B. In further exemplary embodiments of the present invention the sidewall(s) can form the housing.

**[0041]** Multiple waveguides (6A, 6B, and 6C) are shown in the exemplary embodiment of the present invention shown in Figure 6E. As illustrated in Figures 6A-6E, exemplary embodiments of the present invention can have multiple shapes of the waveguide 6, multiple shapes and numbers of the electrodes 2 and 4 (e.g. 2A, 2B, 2C, 4A, 4B, and 4C), multiple numbers of waveguides (e.g., 6A, 6B, and 6C), and multiple numbers of side wall pieces (e.g. 9A, 9B, 9C, and 9D). Additionally, the waveguides can be connected at a location along their lengths. Likewise exemplary embodiments of the present invention can have insulators 10, 10A, 10B, 10C, and 10D to insulate the electrodes from each other. In an exemplary embodiment of the present invention one of the multiple waveguides shown in Figure 6E has no electrodes activated and the chamber acts as a cooling chamber for lasing gas. Where the cooling chamber is one of the waveguides connected to second waveguide somewhere along the length of the waveguide. Where the second waveguide has active electrodes and lasing occurs.

**[0042]** Figure 7 shows a two dimensional lengthwise cross-section of a laser waveguide in accordance with an exemplary embodiment of the present invention. The waveguide 6 has a variable cross-section, in the lengthwise direction, designed specifically for maximizing optical efficiency. The variable cross-section can be of varying shape depending on the optical

modes in the waveguide 6. Although Figure 7 illustrates a symmetric variable shaped cross-section in the lengthwise direction, the shape can be asymmetric or nonsymmetrical.

**[0043]** Additionally the side walls forming the waveguide 6 can be connected by a strip essentially forming one sidewall with two separate sides. If one sidewall is formed then the strip adjoining the two separate sides can cover the surface of one electrode at a position along the length of the waveguide 6. Figure 8 illustrates an exploded view of a laser waveguide in accordance with an exemplary embodiment of the present invention having one sidewall with two main sections 3A and 3B. The main sections 3A and 3B can be connected by a strip 17, forming a single sidewall. The strip 17 can also be used to place the electrodes 2 and 4, and there can be many such strips of various shapes and sizes. The waveguide 6 is formed by two surfaces of the main sections 3A and 3B and surfaces of the two electrodes 2 and 4. The discussion herein should not be interpreted to limit the scope of the present invention to sidewalls with a strip connection or to one sidewall. Exemplary embodiments of the present invention can have multiple non-connected sidewalls.

**[0044]** Protrusions aid in the starting characteristics of a laser. Figures 9A-9C show some exemplary embodiments of the present invention wherein the electrodes 2 and 4 contain protrusions 21. The protrusions 21 of the electrodes 2 and 4 aid in the starting characteristics of a laser by increasing the electric field in a localized region. For example a CO<sub>2</sub> waveguide laser in accordance with an exemplary embodiment of the present invention, having protrusions, can start at 200 Torr pressure as opposed to 70

Torr. The starting pressures given by way of example should not be interpreted to be limitative of the present invention. Lasers in accordance with exemplary embodiments of the present invention can start at various pressures.

**[0045]** In the exemplary embodiments of the present invention described above, the sidewalls (e.g. ,3a, 3b, 3c, 3d, 9A, and 9B) can be constructed of various materials depending on the dielectric properties desired. For example the sidewalls can be constructed of ceramic materials (e.g., Beryllium Oxide (BeO), Aluminium Nitride (AlN),...) , which are far superior in thermal and other characteristics to Aluminium Oxide (Al<sub>2</sub>O<sub>3</sub>), often used in related art waveguide lasers. BeO and AlN are significantly more thermally efficient and significantly more reflective than Al<sub>2</sub>O<sub>3</sub>. For example, BeO is approximately ten times more thermally efficient. Exemplary embodiments of the present invention allow efficient use of the sidewalls such that the above mentioned materials can be used. Exemplary embodiments of the present invention can also use Al<sub>2</sub>O<sub>3</sub>.

**[0046]** In the exemplary embodiments of the present invention the upper (e.g., RF positive electrode) can be continuous to facilitate the distribution of the RF energy, or sectional. The sidewalls and the lower (e.g., ground electrode) can be continuous and/or manufactured in individual sections and assembled. Individual sections aid in reducing overall cost by providing a low cost standard repetitive platform that can be duplicated and aligned to produce a high quality waveguide structure. The sectional structure will result in reduced cost compared to waveguide structures presently in use. The discussion herein should not be interpreted to limit the present invention

to a particular size sectional piece. Various sizes can be used for the length of the sectional pieces besides three inches (e.g., more than 80.0mm, less than 80.0mm) in accordance with exemplary embodiments of the present invention. For example in an eighteen inch laser, three sectional pieces can be approximately six inches in length or in a six inch laser each sectional piece can be two inches in length (if there are three sectional pieces. The discussion herein should not be interpreted to limit the dimensions of the sectional pieces. Exemplary embodiments of the present invention additionally contain various sectional pieces, where the pieces are not of equal length and/or width and/or thickness.

**[0047]** Laser waveguides in accordance with exemplary embodiments of the present invention can have shorter side walls than related art waveguides. If the side walls are formed of sectional pieces, such as less than three inches, ceramics with favorable thermal properties (e.g., BeO, AlN, ...) can be used effectively and at a lower cost. Ceramics with favorable thermal reflectivity properties can maintain a high thermal conductivity while minimizing RF circuit losses.

**[0048]** The pieces can be formed by pressing, sintering or casting. Pressing allows the use of less milling (light milling) to obtain the tolerances needed, thus there is less milling costs. Milling of ceramic is often referred to as grinding. Sintering and casting are relatively cheap. For example, although BeO is approximately twice the price of Al<sub>2</sub>O<sub>3</sub> yet it is approximately ten times more thermally conductive than Al<sub>2</sub>O<sub>3</sub>. AlN is approximately five time more thermally conductive. Since conductivity is greater, less material is



needed, and the resulting cost is reduced. In addition to cost savings, the superior reflectivity available from these materials provides higher efficiency.

**[0049]** In an exemplary embodiment of the present invention a gaseous lasing material is used such as CO<sub>2</sub> or mixtures thereof (e.g. CO<sub>2</sub>, He, N<sub>2</sub>,...). A CO<sub>2</sub> waveguide is unlike a fiber optic waveguide in several relevant respects. The CO<sub>2</sub> waveguide is referred to as a 'leaky mode' waveguide, so gaps in the waveguide are possible and cause little or no adverse changes to the optical properties. Thus, the multiple pieces of ceramic or other suitable material (e.g., BeO, AlN, ...) do not have to be carefully joined and a gap can be left between one piece and the next. The gap can vary in size (e.g., one to three mm or more). Moreover, the top and bottom electrode can be shaped independently of the ceramic and each other, to form a profile that provides a better beam mode profile. For example some or all of the four corners of the waveguide can be rounded to suppress higher order mode formations, and the distance between the top and bottom electrodes can be decreased along the ceramic sidewalls to allow for easier gas discharge initiation while maintaining the same overall gap size and consequently having approximately the same discharge volume (i.e. gain volume).

**[0050]** In exemplary embodiments of the present invention the various shapes of the electrodes allows higher peak power compared to related art devices. Figures 9A-C illustrate various electrode protrusion shapes in accordance with exemplary embodiments of the present invention. The protrusions (also referred to as nips) result in stronger electric fields in a limited regional area, thereby aiding in the startup of the laser. Such

protrusions allow startups at pressures higher than conventional lasers. The increased laser pressure results in an increase of gain volume and subsequent increase pulse power capabilities, but with a decrease in the average power emitted from the laser. An exemplary embodiment of the present invention increases the temporal pulse length to maintain total pulsing power. Thus, quicker start and stop times can be achieved, with increased efficiency, while maintaining total emitted power, when compared to related art devices.

**[0051]** Figure 10 illustrates the connection of at least one power source in accordance with an exemplary embodiment of the present invention. A power source 30 is connected to a connector 12, which feeds power from the power source through the housing 11. In an exemplary embodiment of the present invention the power source is an radio frequency (RF) power source. A RF power supply for any gas laser is composed of one or more RF power transistors and control circuitry for both the transistor(s) and the interface between the RF power supply and the laser. The RF frequency that the transistors generate is unique to every laser but typically is at 40.68, 81.36 or 100 MHz. The control circuitry for the RF power transistors regulates both the RF oscillation and the RF power on/off switching. Conventional RF power systems use relatively old design practices in the transistor drive circuitry, because the RF power transistor's oscillations at 40 to 100 MHz disrupt any microprocessor's circuitry. Consequently the RF power transistor circuitry is presently designed to incorporate discreet components that are virtually insensitive to the power transistor's oscillations.

**[0052]** In an exemplary embodiment of the present invention, the RF power supply can be microprocessor 32 controlled. In this embodiment the microprocessor 32 runs at a frequency higher than the 40 to 100 MHz level of the RF power transistors. For example a processor at ten times the RF power level would be at  $100 \text{ MHz} \times 10 = 1.0 \text{ GHz}$ . Any signal 'picked up' by the GHz processor can be significantly below its noise threshold such that the processor's operation is not impaired. Consequently the microprocessor 32 can replace existing discrete component circuitry that controls the RF power transistors. For example, various parts of the discrete TTL logic circuitry can be replaced by the microprocessor 32, for example a one shot discrete IC, that is part of the RF power transistor's VSWR protection circuit, can be eliminated. Additionally, various gates, opamps and comparators can be eliminated. Other portions of the power system can be replaced by the microprocessor 32 and the discussion herein should not be interpreted to limit the portions replaced.

**[0053]** The use of a microprocessor 32 allows the RF power supply board to be manufactured at a lower cost and for the supply to be significantly smaller. The elimination of numerous discrete components greatly increases the microprocessor based supply's reliability compared to existing designs. The discussion herein is not intended to limit the number or type of microprocessor that can be used with/in the RF power supply.

**[0054]** The description of the invention is merely exemplary in nature and, thus, variations that do not depart from the gist of the invention are intended to be within the scope of the embodiments of the present invention. Such variations are not to be regarded as a departure from the

spirit and scope of the present invention (e.g., other gases besides CO<sub>2</sub> or CO<sub>2</sub> mixtures can be used; protrusions can be used with an all metal system, where the ceramic side walls are replaced with metallic side walls; additional waveguides can be used as coolant chambers,...).

## CLAIMS

What is claimed is:

1. A laser waveguide for use in waveguide lasers comprising:  
an upper electrode, the upper electrode having a first surface;  
and  
a lower electrode, the lower electrode having a second surface,  
where the first surface and second surface are separated by at least one sidewall, where the first surface and the second surface face each other, portions of which are not completely covered by the at least one sidewall, and where the first surface, second surface, and the at least one sidewall form the laser waveguide.
2. The laser waveguide according to claim 1, wherein the at least one sidewall is more than one sidewall.
3. The laser waveguide according to claim 2, wherein the more than one sidewall are sectional sidewalls.
4. The laser waveguide according to claim 3, wherein the sectional sidewalls are separated by sectional gaps.
5. The laser waveguide according to claim 1, wherein the at least one sidewall is made of ceramic.

6. The laser waveguide according to claim 1, wherein the at least one sidewall is made of BeO.
7. The laser waveguide according to claim 1, wherein the at least one sidewall is made of AlN.
8. The laser waveguide according to claim 1, wherein the electrodes are made of metal.
9. The laser waveguide according to claim 3, wherein the sectional sidewalls are under 200.0 mm in length.
10. The laser waveguide according to claim 1, wherein the upper electrode is shaped to form first protrusion(s) that decrease the distance between the first protrusion(s) and the lower electrode.
11. The laser waveguide according to claim 1, wherein the lower electrode is shaped to form first protrusion(s) that decrease the distance between the first protrusion(s) and the upper electrode.
12. The laser waveguide according to claim 10, wherein the lower electrode is shaped to form second protrusion(s) that decrease the distance between the second protrusion(s) and the upper electrode.

13. A waveguide laser comprising:

a laser waveguide, wherein the laser waveguide is formed by electrodes and at least one sidewall such that no surface of the electrodes forming the boundary of the waveguide is completely covered by the at least one sidewall;

an oscillating electromagnetic field, wherein the electromagnetic field is produced by an oscillating current supplied to the electrodes such that the electromagnetic field is produced in the laser waveguide; and

a lasing material placed in the waveguide, wherein the electromagnetic field produces stimulated emission of electromagnetic radiation from the lasing material.

14. The waveguide laser according to claim 13, further comprising:

a RF power supply, where the RF power supply powers the oscillating electromagnetic field; and

a microprocessor; wherein the microprocessor operates at a frequency higher than the frequency of the oscillating electromagnetic field and controls operations of the RF power supply.

15. The waveguide laser according to claim 13, wherein the at least one side wall is more than one sidewall.

16. The waveguide laser according to claim 15, wherein the more than one sidewall are sectional sidewalls.

17. The waveguide laser according to claim 16, wherein the sectional sidewalls are separated by sectional gaps.
18. The waveguide laser according to claim 13, wherein the at least one sidewall is made of ceramic.
19. The waveguide laser according to claim 13, wherein the at least one sidewall is made of BeO.
20. The waveguide laser according to claim 13, wherein the at least one sidewall is made of AlN.
21. The waveguide laser according to claim 13, wherein the electrodes are made of metal.
22. The waveguide laser according to claim 17, wherein the sectional sidewalls are under 200.0 mm in length.
23. The waveguide laser according to claim 13, wherein the upper electrode is shaped to form first protrusion(s) that decrease the distance between the first protrusion(s) and the lower electrode.
24. The waveguide laser according to claim 13, wherein the lower electrode is shaped to form first protrusion(s) that decrease the distance between the first protrusion(s) and the upper electrode.



25. The waveguide laser according to claim 23, wherein the lower electrode is shaped to form second protrusion(s) that decrease the distance between the second protrusion(s) and the upper electrode.

26. The waveguide laser according to claim 13, wherein the lasing material is CO<sub>2</sub>.

27. The waveguide laser according to claim 13, wherein the lasing material is a mixture of CO<sub>2</sub>.

28. A waveguide laser comprising:

a laser waveguide, wherein the laser waveguide is formed by electrodes and at least one sidewall such that no surface of the electrodes forming the boundary of the waveguide is completely covered by the at least one sidewall, where the sidewall has first and second surfaces forming a portion of the laser waveguide, and where the portion varies in distance from the first surface to the second surface along the length of the waveguide;

a housing, where the housing encompasses the laser waveguide and is pressurized to sub-atmospheric pressures;

an oscillating electromagnetic field, wherein the electromagnetic field is produced by an oscillating current supplied to the electrodes such that the electromagnetic field is produced in the laser waveguide; and

a lasing material placed in the waveguide, wherein the electromagnetic field produces stimulated emission of electromagnetic radiation from the lasing material.

29. The waveguide laser according to claim 28, further comprising:

a RF power supply, where the RF power supply powers the oscillating electromagnetic field; and

a microprocessor; wherein the microprocessor operates at a frequency higher than the frequency of the oscillating electromagnetic field and controls operations of the RF power supply.

30. The waveguide laser of claim 28, wherein the housing is formed from the at least one sidewall.

31. The waveguide laser of claim 28, wherein the housing is formed from at least one of the electrodes.

32. The waveguide laser of claim 28, wherein the distance between centerlines of the cross-sections of the electrodes varies along the length of the waveguide.

33. The waveguide laser of claim 28, wherein the distance between the first and second surfaces varies along the length of the waveguide.

34. A method of forming a laser waveguide comprising:

placing an upper electrode, the upper electrode having a first surface with a protrusion;

positioning at least one sidewall on the first surface, such that the at least one sidewall does not completely cover the first surface; and

positioning a lower electrode on the at least one sidewall, the lower electrode having a second surface, where the at least one sidewall does not completely cover the second surface, and where the placement of the upper electrode, positioning of the lower electrode and the at least one sidewall, forms a laser waveguide having a compact structure.

35. The method of claim 34, further comprising:

forming the at least one sidewall, where the forming step is comprised of:

pressing at least one ceramic piece into a desired shape; and  
grinding the at least one ceramic piece to a first tolerance.

36. The method of claim 34, further comprising:

forming the lower electrode, where the forming step is comprised of:

milling the lower electrode to a second tolerance.

37. The method of claim 34, further comprising:

forming the upper electrode, where the forming step is comprised of:

milling the upper electrode to a third tolerance.

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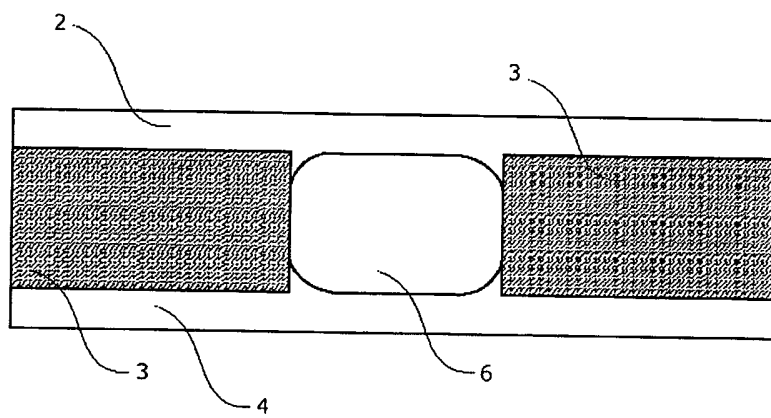
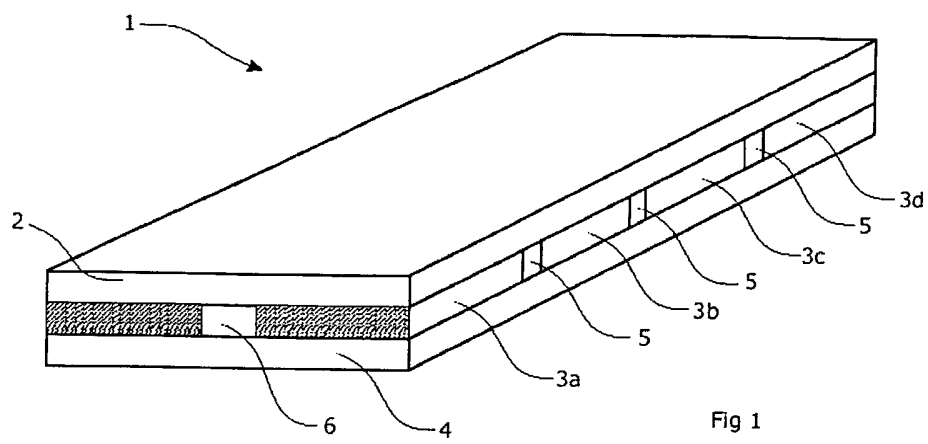
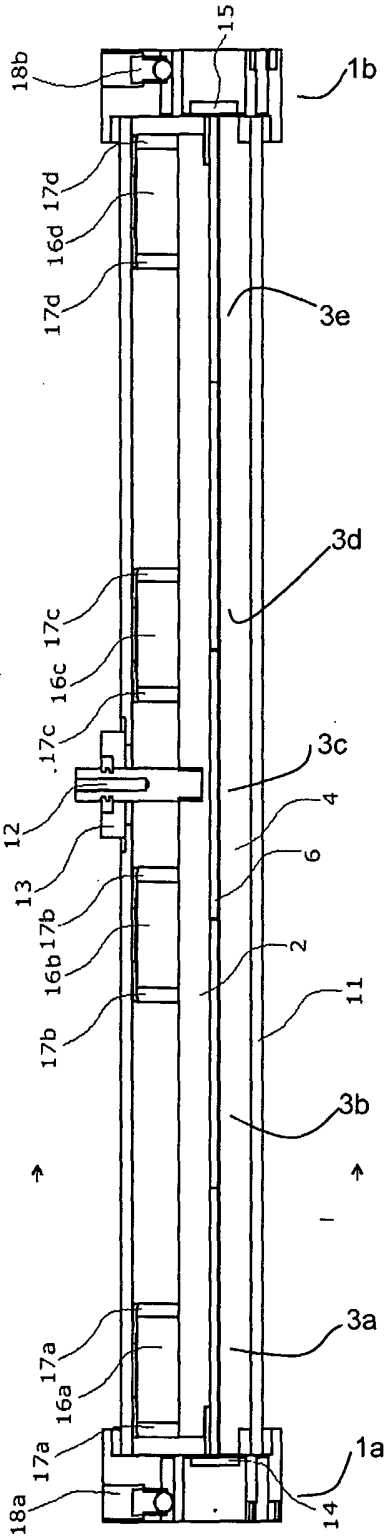
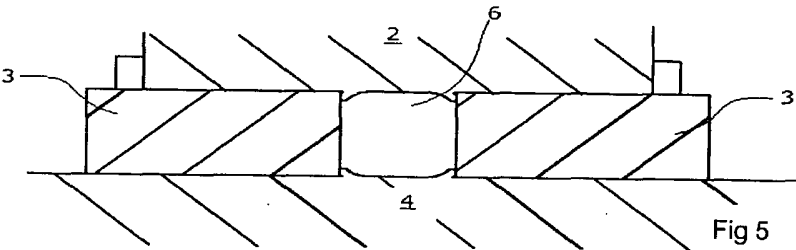
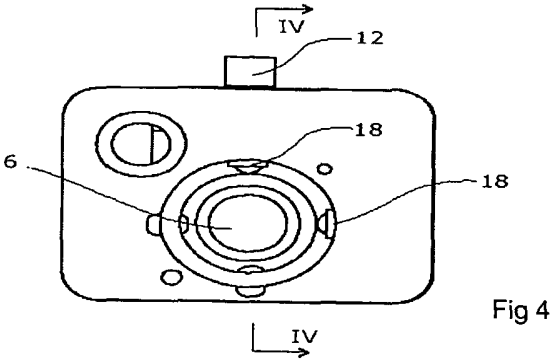


Fig 3





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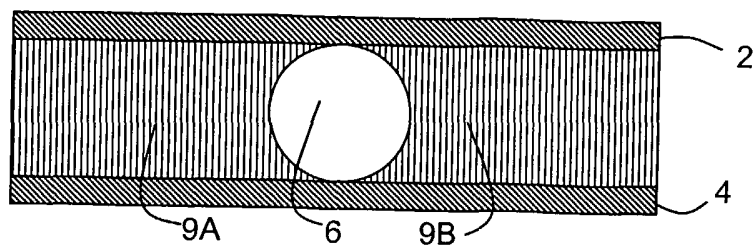


Fig. 6A

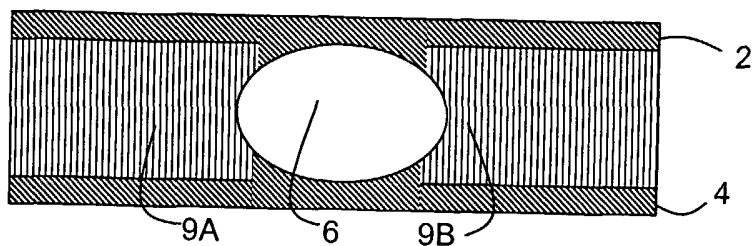


Fig. 6B

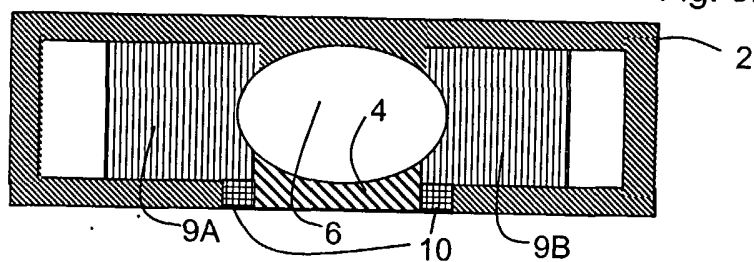


Fig. 6C

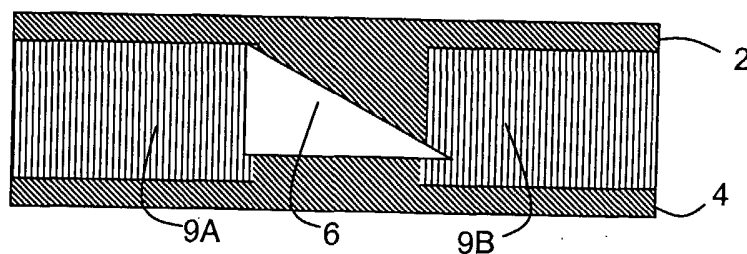


Fig. 6D

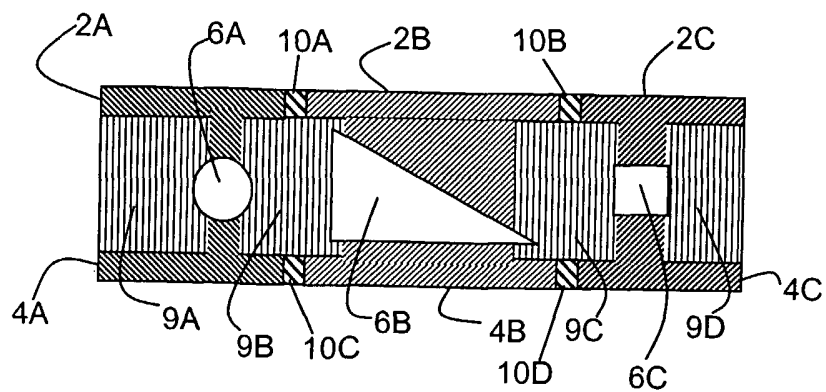


Fig. 6E

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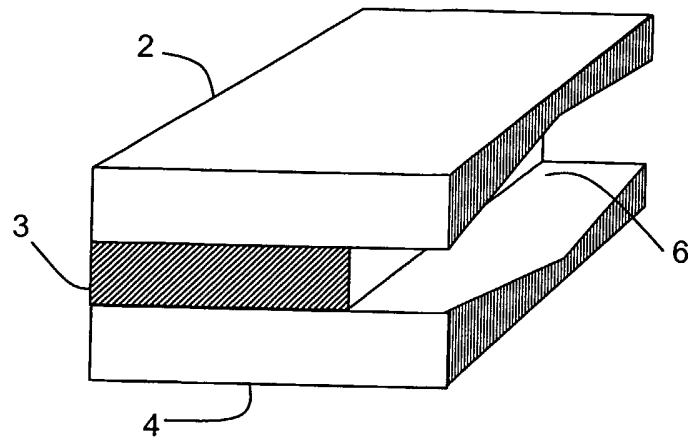


Fig. 7

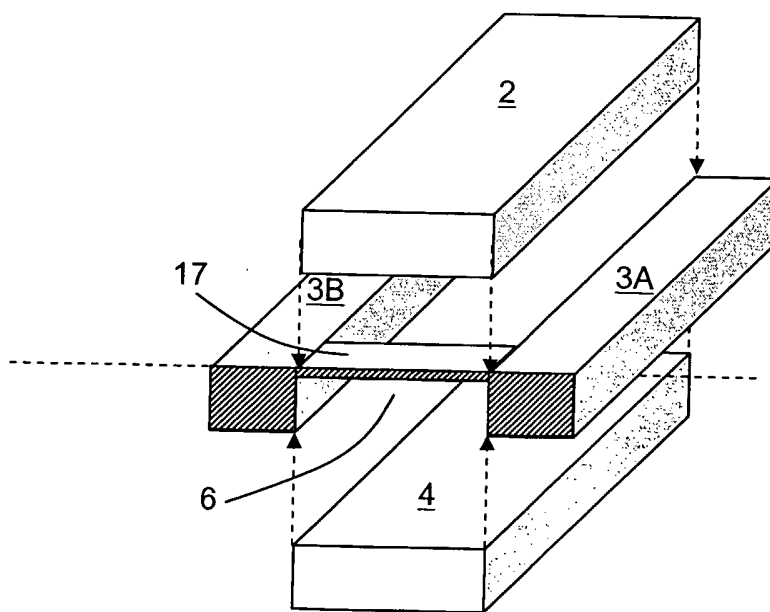


Fig. 8



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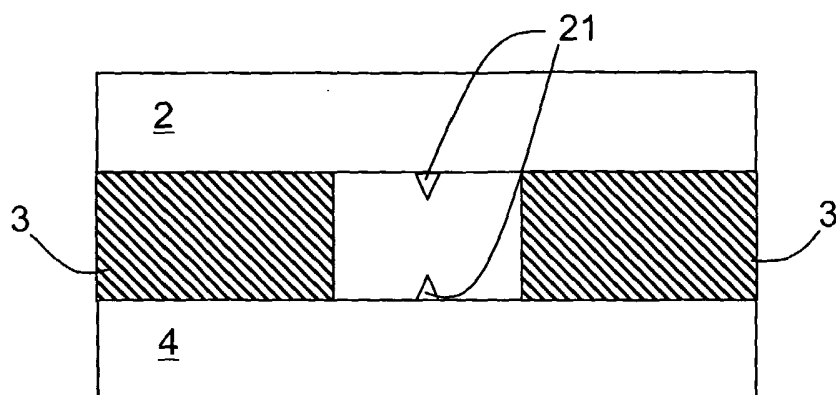


Fig. 9A

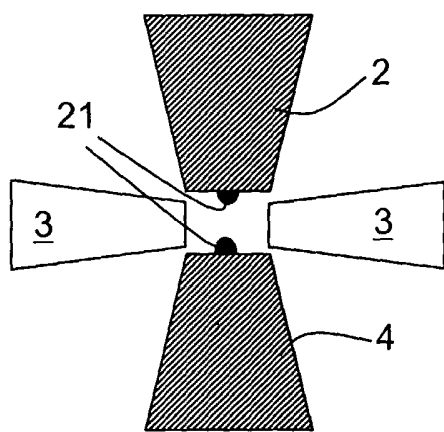


Fig. 9B

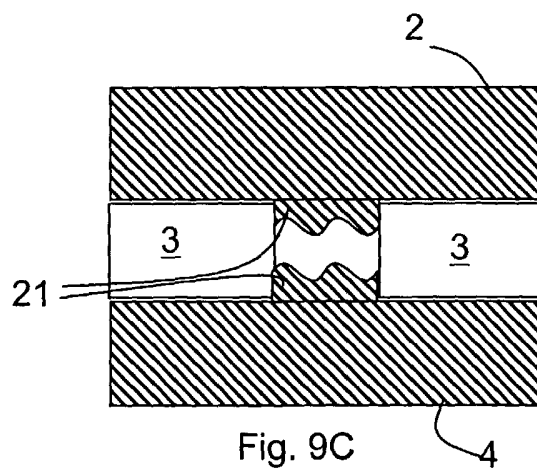


Fig. 9C

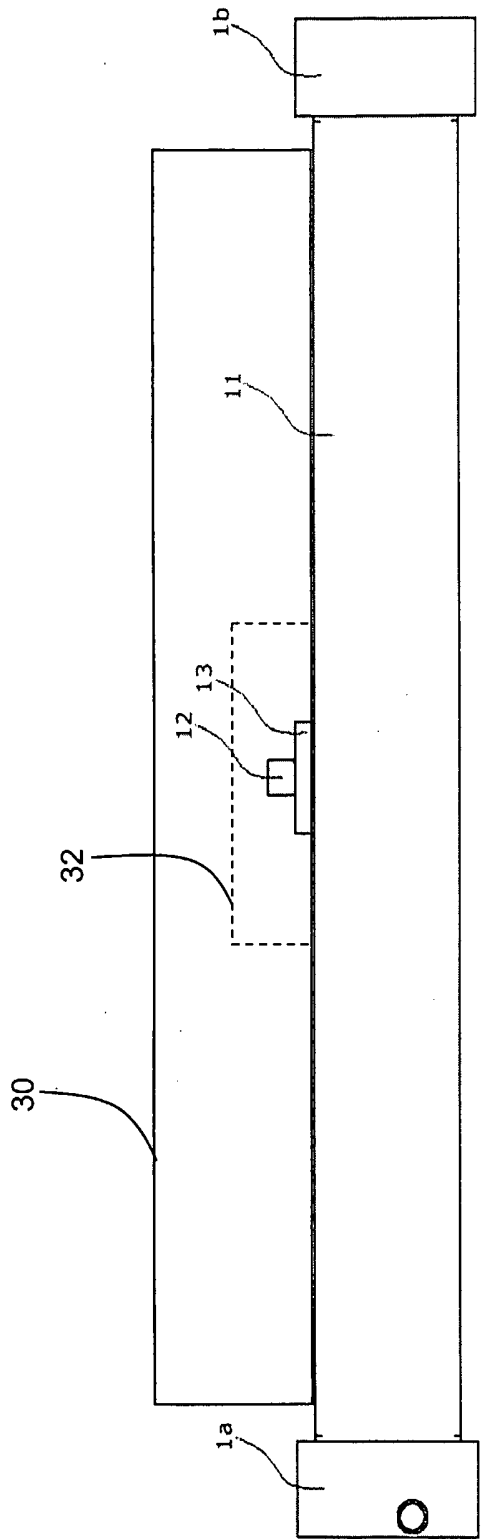


Fig. 10